

Article

Preparation of Surface Dispersed WO₃/BiVO₄ Heterojunction Arrays and Their Photoelectrochemical Performance for Water Splitting

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Abstract: In this work, a surface dispersed heterojunction of BiVO₄-nanoparticle@WO₃-nanoflake was successfully prepared by hydrothermal combined with solvothermal method. We optimized the morphology of the WO₃ nanoflakes and BiVO₄ nanoparticles by controlling the synthesis conditions to get the uniform BiVO₄ loaded on the surface of WO₃ arrays. The phase composition and morphology evolution with different reaction precursors were investigated in detail. When used as photoanodes, the WO₃/BiVO₄ composite exhibits superior activity with photocurrent at 3.53 mA cm^{−2} for photoelectrochemical (PEC) water oxidation, which is twice that of pure WO₃ photoanode. The superior surface dispersion structure of the BiVO₄-nanoparticle@WO₃-nanoflake heterojunction ensures a large effective heterojunction area and relieves the interfacial hole accumulation at the same time, which contributes to the improved photocurrents together with the stability of the WO₃/BiVO₄ photoanodes.

Keywords: bismuth vanadate; tungsten oxide; heterojunction; surface dispersed heterojunction; photoelectrochemical water oxidation



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1. Introduction

Photoelectrochemical (PEC) water splitting provides a promising strategy to relieve global energy demands and environmental problems as it can harvest solar energy and convert it into chemical energy in the form of a reaction product of hydrogen [1–4]. In a PEC system, the photoanode, where the oxygen evolution reaction (OER) takes place, suffers from sluggish kinetics and appears to be a rate-limiting step [5,6]. It is of great significance to searching for effective photoanodes.

Among the promising photoanode materials, WO₃, which is featured with electron mobility of 10 cm² V^{−1} s^{−1}, electron diffusion length of ~500 nm and hole diffusion distance of ~150 nm [7,8], has significant advantages in charge carrier transport characteristics over other common semiconductors, such as TiO₂ [9–11], ZnO [12,13] and α-Fe₂O₃ [14–16]. However, although WO₃ can respond to visible light to some extent, the large band gap still leads to limited visible light absorption [17,18]. Thus, the theoretical solar to hydrogen (STH) efficiency of WO₃ is only about 4.5% [19]. BiVO₄ possesses a narrow band gap of ~2.4 eV, which can absorb a large part of the visible light with the wavelength below 520 nm [20,21]. The band gap determines that the maximum theoretical water oxidation photocurrent of BiVO₄ photoanode is 7.5 mA cm^{−2} under standard solar radiation (AM 1.5 G) and STH efficiency is close to 9.2% [22]. In addition, BiVO₄ has the advantages of light corrosion resistance. However, the electron mobility of BiVO₄ is poor [20], which

causes an imbalance between the efficiency of light harvest and charge separation in BiVO_4 . This is the bottleneck of BiVO_4 photoanodes.

It has been reported that the construction of the $\text{WO}_3/\text{BiVO}_4$ heterojunction can integrate the advantages of WO_3 and BiVO_4 , where WO_3 can serve as carrier conduction layer and BiVO_4 as the main absorber toward visible light [23–25]. As a result, the heterojunction can not only widen the range of light utilization, but also promote the effective charge separation [26]. In 2011, Suk Joon Hong et al. first prepared a series of $\text{WO}_3/\text{BiVO}_4$ heterojunctions with different WO_3 or BiVO_4 thicknesses, and it was reported that the obtained photocurrents were closely related to the $\text{WO}_3/\text{BiVO}_4$ structure [27]. From then, new structures of $\text{WO}_3/\text{BiVO}_4$ heterojunctions were further developed, such as 1D nanorod core-shell [28,29], 2D nanosheet core-shell [30] and 3D inverse opal structures [31,32]. However, the structural optimization mainly focused on the morphology and pore distribution of the underlying WO_3 ; there are still few reports on the upper BiVO_4 layer. Most studies reported the $\text{WO}_3/\text{BiVO}_4$ heterojunction adopting the spin or drop coating to deposit a conformal BiVO_4 layer onto the WO_3 [33–38]. However, this process is complex and needs repeated coating and annealing. Moreover, it often gives a non-uniform coating layer on the surface of WO_3 .

It has been reported that there are mainly three kinds of heterojunction configurations: (1) the planar laminations, which can be easily prepared by combining different semiconductor layers, but the planar structure severely limits the active area of electrodes; (2) the core-shell coaxial structure, which can significantly improve the effective heterojunction area, but the holes generated by the inner semiconductor can only be transmitted to the surface semiconductor through the heterojunction, which might lead to the accumulation of charge carriers at the semiconductor interface; and (3) the surface dispersion structure, which can ensure that both kinds of semiconductor can accept light and participate in the surface reaction, and at the same time remaining a large effective heterojunction area. Therefore, to fabricate the surface dispersed $\text{WO}_3/\text{BiVO}_4$ heterojunction arrays shows great potential to improve its performance toward PEC water oxidation. Hyungtak Seo et al. [39] used ethyl cellulose as the morphology control agent and prepared BiVO_4 with island morphology decorated on the WO_3 layer via the spin coating. Ho Won Jang et al. [40] prepared dot-like BiVO_4 coated on the entire surface of WO_3 nanorods by pulse electrodeposition, which could significantly increase the active area of the heterojunction. Kiyoung Lee et al. [41] investigated the interfacial growth of the optimal BiVO_4 nanoparticles onto WO_3 nanoplates via a chemical bath deposition method; however, it still could not avoid the ten times of repeated coating procedure. Hongbing Yu et al. [42] synthesized the coral-like $\text{WO}_3/\text{BiVO}_4$ photoanode via BiOI electrodeposition with a relatively complex process. Huixia Guo et al. [43] reported the synthesis of BiVO_4 nanoparticles on the WO_3 thin film by hydrothermal method; however, the structure still needs to be optimized to decrease the particle agglomeration.

In this work, the surface dispersed heterojunction structure of BiVO_4 -nanoparticle@ WO_3 -nanoflake was prepared by the hydrothermal combined with solution-thermal method to obtain high PEC water splitting performance. Firstly, WO_3 nanoflake arrays with optimized properties were obtained by changing the synthesis conditions and controlling the morphology of WO_3 films by hydrothermal method. Afterwards, uniform BiVO_4 nanoparticles were covered on the surface of WO_3 nanoflake arrays through the secondary solvothermal process. As a result of the formation of $\text{WO}_3/\text{BiVO}_4$ heterojunction and its well-arranged structure, the performance of the surface dispersed $\text{WO}_3/\text{BiVO}_4$ arrays was significantly improved compared with pure WO_3 nanoflake arrays.

2. Results and Discussion

2.1. Structure and Properties of WO_3 Nanoflake Arrays

Firstly, the WO_3 morphology was optimized by changing the concentration of hydrothermal precursors. Figures 1 and 2 exhibit SEM images of different WO_3 films from the top and cross-sectional view, respectively. It can be seen that all of the WO_3 films are fea-

tured with nanoflake structure, which are arranged directly onto the FTO substrate. When the concentration of sodium tungstate in precursor solution is low (10 mM), nanoflower clusters assembled by thin nanoflakes appear in WO₃-a, which are uniformly distributed on FTO substrate with a relatively large exposed FTO space. As seen in Figure 2a, the thickness of the WO₃-a array is about 1.2 μm . As for WO₃-b, the distribution of the WO₃ nanoflower structure gets distinctly denser with less exposed area of FTO (Figure 1(b1–b3)) and the thickness of the nanoflake array increases slightly to 1.3 μm (Figure 2b). When the concentration of sodium tungstate solution is increased to 20 mM, no nanoflowers appeared in WO₃-c, where the morphology in a wide field of vision is the uniform nanoflake array. There is no FTO substrate exposed. As seen in Figure 2c, the thickness of WO₃-c is about 1.5 μm . When the concentration of sodium tungstate solution is further increased to 50 or 80 mM, the WO₃-c and WO₃-d nanoflakes seen from the top view do not change much, with a slightly denser arrangement of the WO₃ nanoflakes (Figure 1(d1–d3,e1–e3)). However, the thickness of the nanoflake arrays changes significantly.

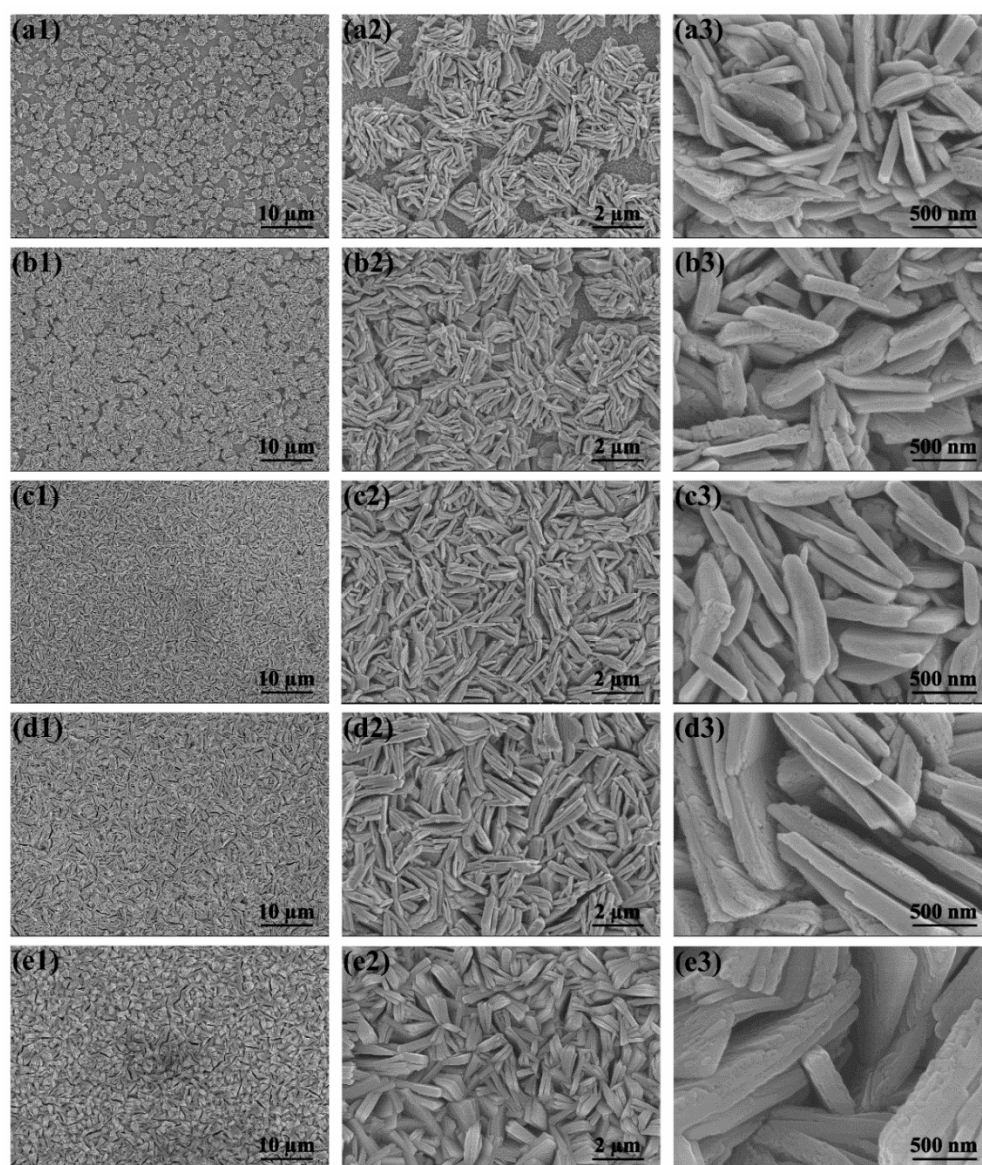


Figure 1. Top view SEM images of different WO₃ arrays: (a1–a3) WO₃-a, (b1–b3) WO₃-b, (c1–c3) WO₃-c, (d1–d3) WO₃-d and (e1–e3) WO₃-e.

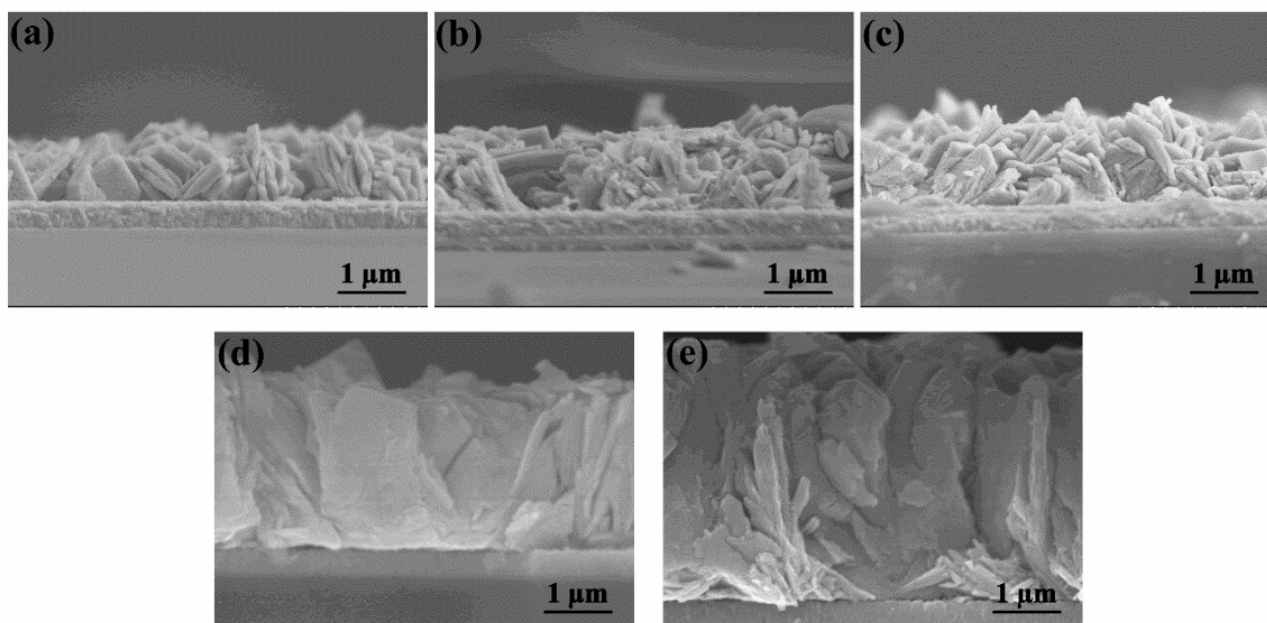


Figure 2. Cross-sectional view SEM images of the WO_3 arrays: (a) WO_3 -a, (b) WO_3 -b, (c) WO_3 -c, (d) WO_3 -d and (e) WO_3 -e.

As seen in Figure 2d, the thickness of WO_3 -d is about $3.2\ \mu\text{m}$, which is almost twice that of WO_3 -c. When the concentration of the sodium tungstate solution further increases to 80 mM, the thickness of the WO_3 -e array increases to $4.0\ \mu\text{m}$ (Figure 2e). Combined with the images from Figures 1 and 2, it can be concluded that the increase in precursor concentration in the initial stage mainly causes changes in the coverage of the film and the density of the nanoflakes, while the thickness of the WO_3 array changes little. Whereas, when the nanoflakes completely cover the FTO substrate, further increase in precursor concentration mainly causes the increase in the thickness of the WO_3 nanoflake array. Moreover, the morphology of nanoflake arrays directly grown on FTO substrates can not only provide a large specific surface area, but also facilitate the efficient transfer of photogenerated electrons to the FTO collector.

To confirm the phase composition of the WO_3 arrays, Figure 3 gives the XRD patterns of WO_3 arrays obtained through the hydrothermal process before and after heat treatment. Taking WO_3 -d in Figure 3a as an example, before heat treatment, strong diffraction peaks appear at 16.5° , 19.3° , 23.8° , 25.7° , 30.5° , 35.1° , 38.9° , 49.2° and 52.9° , which respectively can be corresponded to the crystal faces of (020), (011), (120), (111), (031), (002), (022), (042) and (222) from $\text{WO}_3 \cdot \text{H}_2\text{O}$ (JCPDS No. 43-0679). The diffraction peaks marked by black dots are from the FTO substrate. The XRD patterns of WO_3 arrays prepared after calcination are given in Figure 3b. There are no diffraction peaks corresponding to $\text{WO}_3 \cdot \text{H}_2\text{O}$, indicating that all of the $\text{WO}_3 \cdot \text{H}_2\text{O}$ phase has inverted after heat treatment at 500°C . Instead, all of the peaks are from monoclinic tungsten oxide (JCPDS 43-1035), where the respective peaks at 23.1° , 23.6° , 24.4° , 34.2° and 50.0° can, respectively, be ascribed to the (002), (020), (200), (202) and (140) crystal planes [44]. In addition, it can be seen that after the same synthesis process, the intensity of WO_3 diffraction peak gradually increases with the increase in the precursor concentration. These results are consistent with the SEM images that as the concentration of sodium tungstate solution increases, WO_3 nanoflakes gradually cover the FTO substrate and then increase in thickness.

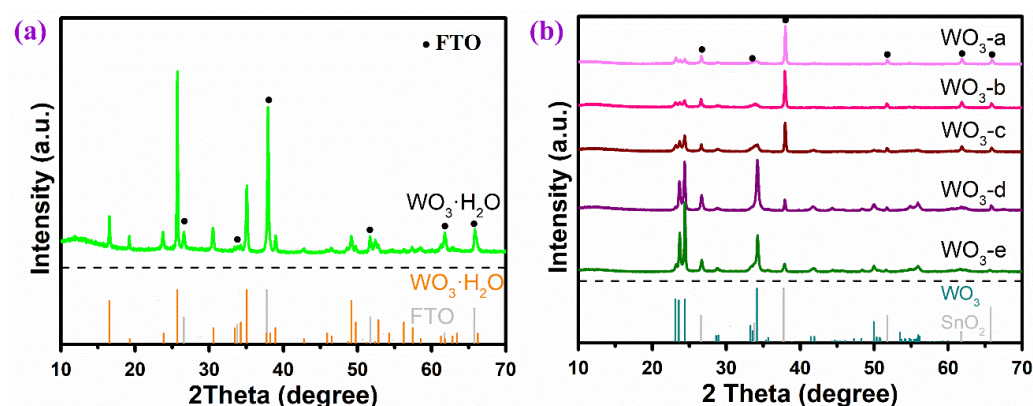


Figure 3. X-ray diffraction (XRD) patterns of WO₃ arrays (a) before and (b) after heat treatment.

The photoelectrochemical water splitting performance of different WO₃ nanoarrays was studied by using them as the working electrodes and the results are shown in Figure 4. According to the linear sweep voltammograms curve (LSV) in Figure 4a, under illumination the onset potential of each WO₃ array is similar, which is about 0.69 V (vs. RHE). For WO₃-a, it has the lowest water splitting performance with a photocurrent at 1.23 V (vs. RHE) being 0.92 mA cm⁻². According to the UV-Visible light absorption performance (Supplementary Figure S1), WO₃-a has limited absorption of incident light. The insufficient photogenerated electrons and holes lead to the lowest photocurrent. With the increase in precursor concentration, the photocurrent gradually increases, where the photocurrent of WO₃-b, WO₃-c and WO₃-d is 1.26, 1.50 and 1.69 mA cm⁻², respectively. When the concentration of precursor solution is further increased, the photocurrent of WO₃-e decreased to 1.63 mA cm⁻². Combined with the SEM images, the WO₃ nanoflake arrays initially get denser and thicker with the increase in the precursor solution concentration, which can increase the light absorption and photocarrier generation so as to improve the photocurrent of photoelectrochemical water oxidation. On the contrary, the thick film of WO₃-e could extend the distance of photogenerated electrons to the FTO collector, which increases the probability of carrier recombination and is not conducive to the effective separation of carriers. Thus, the WO₃-d shows the largest photocurrent as a result of a balance of photocarrier generation and separation. Figure 4b shows the curves of applied bias photon-to-current (ABPE) conversion efficiency at the applied bias of 0.98 V (vs. RHE). Among them, the ABPE of WO₃-d reaches the maximum value at about 0.23%, indicating that it has a good photon-to-current conversion efficiency.

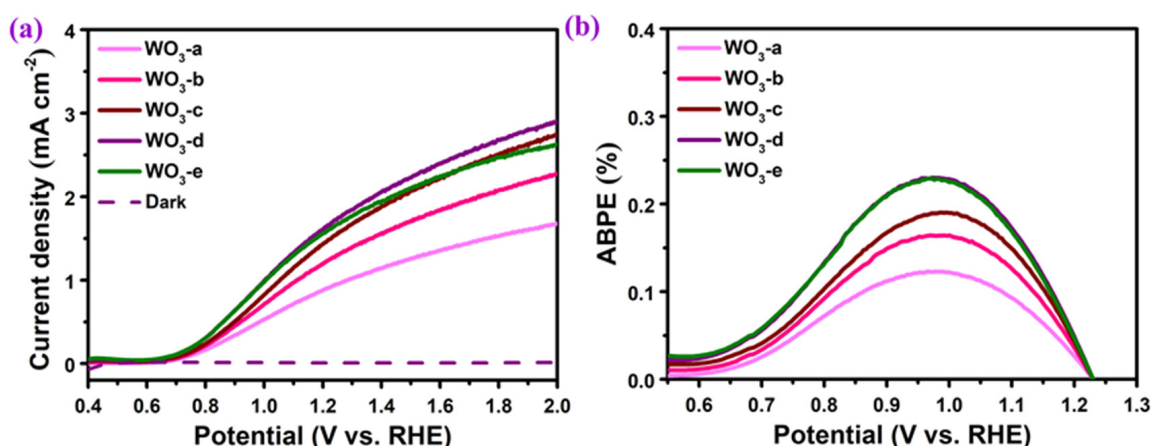


Figure 4. (a) Linear sweep voltammograms (LSV) and (b) the applied bias photon-to-current efficiency (ABPE) curves of WO₃ arrays.

2.2. Structure and Properties of WO₃/BiVO₄ Nanoarrays

Based on the structure and properties of the WO₃ arrays, WO₃-d was chosen to composite BiVO₄ for further research. Figure 5 gives the XRD patterns of the WO₃/BiVO₄ composite array prepared with different concentrations of BiVO₄ precursors. In addition to the peaks of WO₃ and FTO substrate (marked with black circles), new weak peaks appear, and the intensity of these peaks gradually increases with the increase in the concentration of BiVO₄ precursor solution. Taking WO₃ and WO₃/BiVO₄-10 as an example, it can be seen from the magnified XRD in Figure 5b that new diffraction peaks at 18.7°, 28.6°, 28.8°, 28.9° and 30.5° in WO₃/BiVO₄-10 can, respectively, be corresponded to the (110), (−130), (−121), (121) and (040) crystal faces of monoclinic scheelite BiVO₄ (JCPDS No. 14-0688) [45]. Therefore, the existence of BiVO₄ is proved, and the relatively weak diffraction peaks of BiVO₄ might be ascribed to the low content of BiVO₄. The small peak around 27.8° can be assigned to the (011) crystal face of the tiny VO₂ (JCPDS No. 43-1051) after the hydrothermal route.

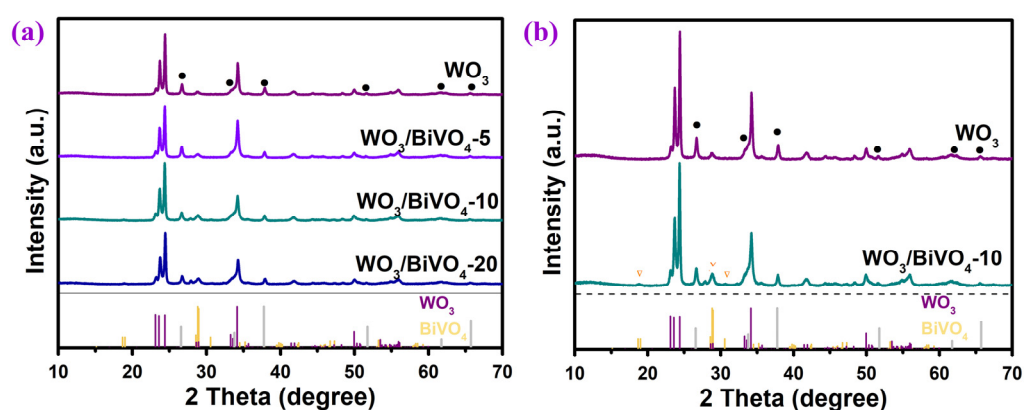


Figure 5. (a) X-ray diffraction (XRD) patterns of WO₃ and WO₃/BiVO₄ nanoarrays and (b) enlarged X-ray diffraction (XRD) patterns of WO₃ and WO₃/BiVO₄-10.

The morphology of the WO₃/BiVO₄ composite prepared with different concentrations of BiVO₄ precursor solution were observed by SEM. As shown in Figure 6, the nanoflake structure of the WO₃ array was still maintained after solvothermal reaction. From the morphology of WO₃/BiVO₄-5 in Figure 6b, small nanoparticles can be clearly verified on the WO₃ nanoflake with a particle size of ~20 nm, which are uniformly attached to the WO₃ nanoflakes. As the reaction concentration of precursors increases, the distributed BiVO₄ on the surface of the WO₃ nanoflake becomes denser. For WO₃/BiVO₄-10, it can be seen from Figure 6c that the size of BiVO₄ nanoparticles increases to ~50 nm and there is a uniform dispersion of BiVO₄ nanoparticles on the surface of the entire WO₃ nanoflake array. When the reaction concentration further rises to 20 mM, as shown in Figure 6d, WO₃/BiVO₄-20 is covered with not only uniform BiVO₄ nanoparticles but also aggregated nanoparticles. As shown in Supplementary Figure S2, the size of large BiVO₄ particles in WO₃/BiVO₄-20 can be as large as ~1 μm. Therefore, by controlling the proper precursor concentration, the surface dispersed morphology of BiVO₄ nanoparticles on the surface of WO₃ nanoflakes is fabricated, which is conducive to expanding the interfacial surface area and increasing the reactive sites.

The cross-sectional SEM image of WO₃/BiVO₄-10 is illustrated in Supplementary Figure S3. The thickness of WO₃/BiVO₄-10 is similar to that of the pure WO₃ arrays, which means the solvothermal progress does not change the morphology of WO₃ arrays. BiVO₄ nanoparticles can also be verified from the cross-sectional view, further indicating the formation of the surface dispersed morphology of BiVO₄-nanoparticle@WO₃-nanoflake. Sn distribution is consistent with the position of FTO substrate. From the element mapping, Bi, V, W and O elements are distributed uniformly, indicating that BiVO₄ particles are uniformly loaded on the entire longitudinal WO₃ nanoflakes.

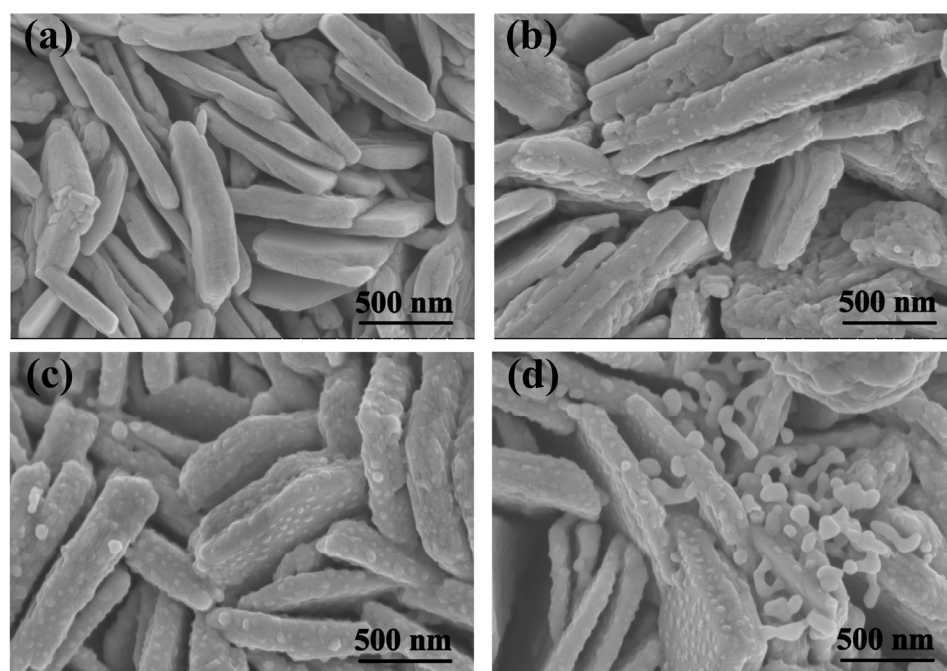


Figure 6. SEM images of WO_3 and $\text{WO}_3/\text{BiVO}_4$ composite arrays; (a) WO_3 , (b) $\text{WO}_3/\text{BiVO}_4$ -5, (c) $\text{WO}_3/\text{BiVO}_4$ -10 and (d) $\text{WO}_3/\text{BiVO}_4$ -20.

Representative XPS spectra were tested to study the chemical elemental composition and the corresponding elemental valence states of the WO_3 and $\text{WO}_3/\text{BiVO}_4$ arrays. The survey spectrum in Figure 7a proves that WO_3 contains W and O elements, while $\text{WO}_3/\text{BiVO}_4$ -10 contains Bi, V, W and O elements. From the high-resolution spectra of Bi 4f and V 2p in Figure 7b,c, the WO_3 array shows basically a straight line. After BiVO_4 loaded, $\text{WO}_3/\text{BiVO}_4$ -10 showed two peaks at 164.2 and 158.9 eV, ascribed to the binding energy of Bi 4f_{5/2} and Bi 4f_{7/2}, respectively. This indicates that the Bi element is presented in the form of Bi^{3+} [46]. The binding energies at 524.1 and 516.5 eV indicate the existence of V 2p_{1/2} and V 2p_{3/2} [47]. According to the high-resolution XPS spectra of W 4f in Figure 7d, the binding energies of W 4f_{5/2} and W 4f_{7/2} in the WO_3 nanoarrays are located at 35.4 and 37.6 eV, which proves the chemical state of W element in the form of W^{6+} [44]. For the $\text{WO}_3/\text{BiVO}_4$ composite array, the intensity of W 4f spectrum is obviously weakened after the deposition of BiVO_4 on WO_3 . In addition, the binding energy of W 4f moves towards the lower energy direction, which proves that there is a strong interaction between WO_3 and BiVO_4 , which is beneficial for electron conduction. The high-resolution XPS spectra of O 1s shown in Figure 7e can be fitted into two peaks located at 530.1 and 531.4 eV, corresponding to lattice oxygen and defect sites with low oxygen coordination (i.e., hydroxyl), respectively.

The $\text{WO}_3/\text{BiVO}_4$ -10 composite array was scraped off the substrate for TEM test. A representative image is shown in Figure 8a and its corresponding HRTEM image is shown in Figure 8b, where the lattice spacing from the nanoflake structure is around 0.27 nm, ascribed to the (022) interplanar spacing of monoclinic WO_3 . The lattice spacing of surface loaded particles is ~0.31 nm, which is consistent with the (−121) crystal plane of BiVO_4 . In addition, the tight lattice connection between BiVO_4 and WO_3 further indicates a good binding between BiVO_4 and WO_3 . From Figure 8c, the nanoflake structure of WO_3 can be distinguished. As shown in the element distribution images (Figure 8d), W element can be seen in the whole field of vision, while Bi and V elements are relatively distributed in the marginal region corresponding to small particles. The distribution of Bi, V, W and O elements indicates that BiVO_4 is evenly distributed on the surface of WO_3 .

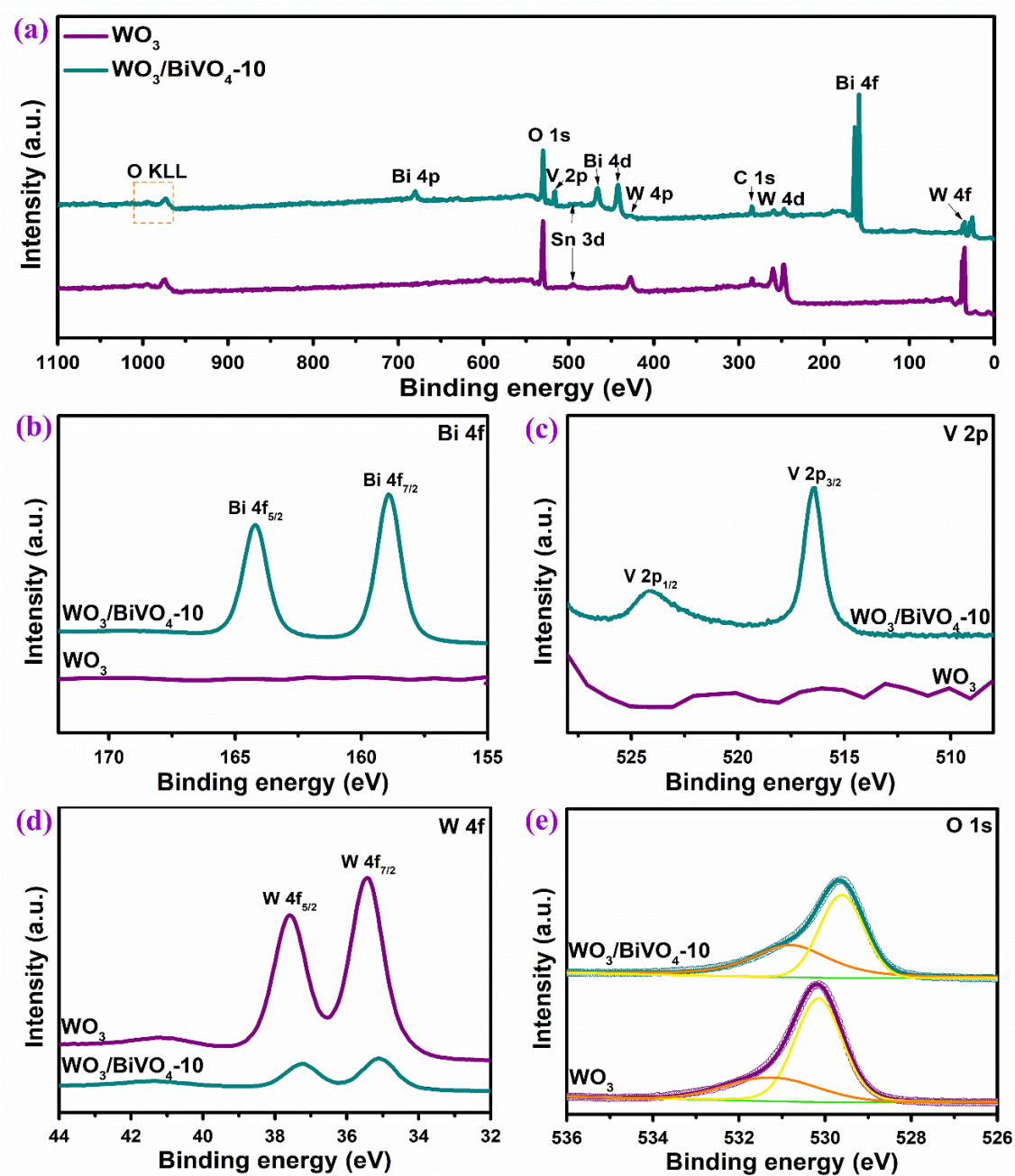


Figure 7. XPS spectra of WO_3 and $\text{WO}_3/\text{BiVO}_4$ -10, (a) survey spectrum where the orange square and the black arrows represent the binding energy of the corresponding element. High-resolution XPS spectra of (b) Bi 4p, (c) V 2p, (d) W 4f and (e) O 1s.

Figure 9 is the optical absorption performance of WO_3 and $\text{WO}_3/\text{BiVO}_4$ arrays. Pure WO_3 exhibits a light response to ultraviolet light and part of visible light. After loading BiVO_4 , the light response range of the $\text{WO}_3/\text{BiVO}_4$ array shows an obvious red shift, but the light absorption intensity is similar in the ultraviolet region. The results show that the absorbed light of 400–480 nm is mainly due to the contribution of BiVO_4 , and the utilization of visible light by $\text{WO}_3/\text{BiVO}_4$ is significantly improved after loading BiVO_4 . The corresponding Tauc curve is given in Figure 9b, where the band gap can be estimated by extending the linear part of the curve. The band gap of the $\text{WO}_3/\text{BiVO}_4$ composite array is about 2.50 eV, which is significantly reduced compared with that of the pure WO_3 array (2.64 eV), indicating a wider light spectrum of the $\text{WO}_3/\text{BiVO}_4$ composite.

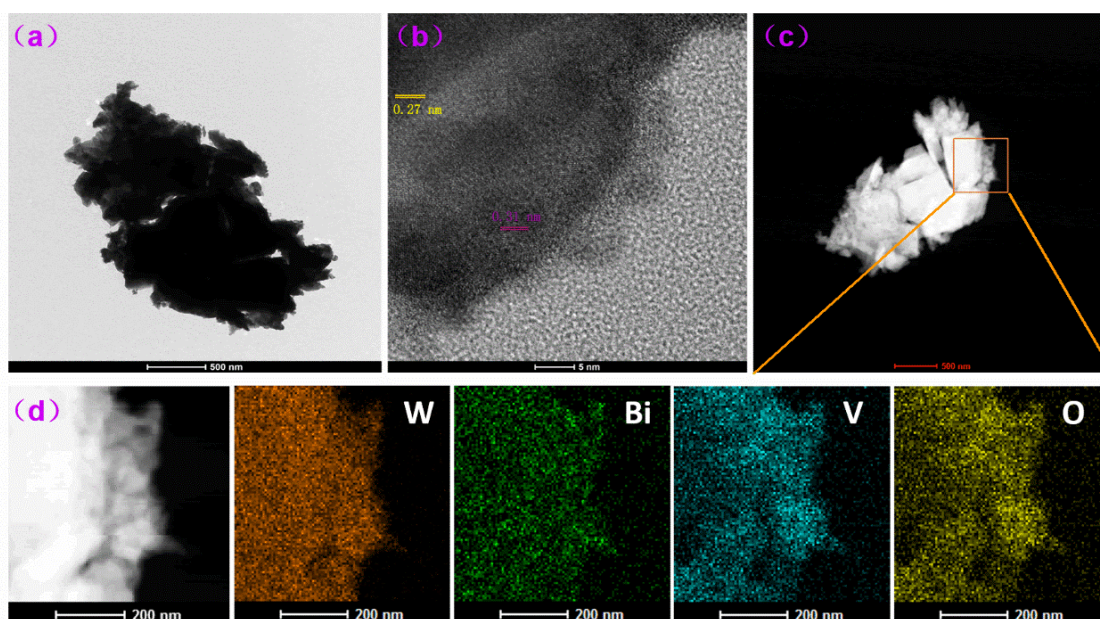


Figure 8. (a) TEM, (b) HRTEM and (c,d) EDS element distribution images of $\text{WO}_3/\text{BiVO}_4$ -10 arrays ((d) zooms in of marked square region in (c)).

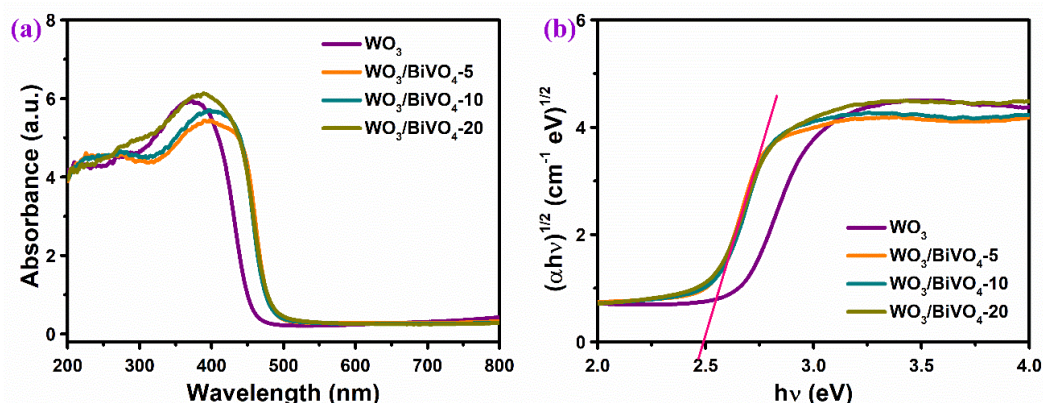


Figure 9. (a) UV-vis absorption spectra and (b) Tauc plots of WO_3 and $\text{WO}_3/\text{BiVO}_4$ arrays.

The performance of WO_3 and $\text{WO}_3/\text{BiVO}_4$ toward photoelectrochemical water oxidation was measured by using the WO_3 and $\text{WO}_3/\text{BiVO}_4$ arrays as photoanodes. As shown in the linear sweep voltammograms curves (Figure 10a), the properties of $\text{WO}_3/\text{BiVO}_4$ are significantly improved compared with pure WO_3 . The dashed line represents the LSV curve of $\text{WO}_3/\text{BiVO}_4$ in the dark, which indicates the significant photoresponse of all photoanodes. As mentioned above, the photocurrent at 1.23 V (vs. RHE) of pure WO_3 is 1.69 mA cm^{-2} . After loading BiVO_4 , the photocurrent of $\text{WO}_3/\text{BiVO}_4$ -5 was significantly increased to 2.57 mA cm^{-2} . According to the above analysis, the absorption of visible light in the $\text{WO}_3/\text{BiVO}_4$ composite array is significantly increased, and the formation of the heterojunction structure between WO_3 and BiVO_4 is conducive to the effective separation of photogenerated carriers. As for the $\text{WO}_3/\text{BiVO}_4$ -10 photoanode, the highest photocurrent at 3.53 mA cm^{-2} is observed. This performance may be due to the appropriate loading amount and excellent dispersion of BiVO_4 in $\text{WO}_3/\text{BiVO}_4$ -10, which enables the sufficient light absorption and effective carrier separation at the same time. As a result, more carriers can effectively transfer to the electrode surface for PEC OER reactions to take place. The key characteristics of recent reported $\text{WO}_3/\text{BiVO}_4$ heterojunction photoanodes without an additional catalyst or doping for solar water oxidation are summarized in Table 1. Considering that the photocurrent can be significantly improved if there is the hole scavenger in

the electrolyte, the performance of the surface dispersed $\text{WO}_3/\text{BiVO}_4$ nanoplates in our work are among the best. In the case of $\text{WO}_3/\text{BiVO}_4$ -20, the photocurrent then decreases to 2.95 mA cm^{-2} . It has been reported that the short life of photogenerated electrons is the main drawback of the PEC performance of BiVO_4 . The agglomeration and the existence of large size BiVO_4 in $\text{WO}_3/\text{BiVO}_4$ -20 might hinder the effective carrier transfer, resulting in the decreased photocurrent in spite of the increased BiVO_4 loading. Figure 10b shows the i - t curves of WO_3 and the $\text{WO}_3/\text{BiVO}_4$ arrays measured with chopped light illumination. All the photoelectrodes exhibit prompt response toward light, indicating that the photoanode material has excellent transfer ability of photogenerated electrons and holes. The photocurrents of WO_3 , $\text{WO}_3/\text{BiVO}_4$ -5, $\text{WO}_3/\text{BiVO}_4$ -10 and $\text{WO}_3/\text{BiVO}_4$ -20 photoanodes are 1.69, 2.84, 3.92 and 2.30 mA cm^{-2} , which is consistent with the trend of LSV results.

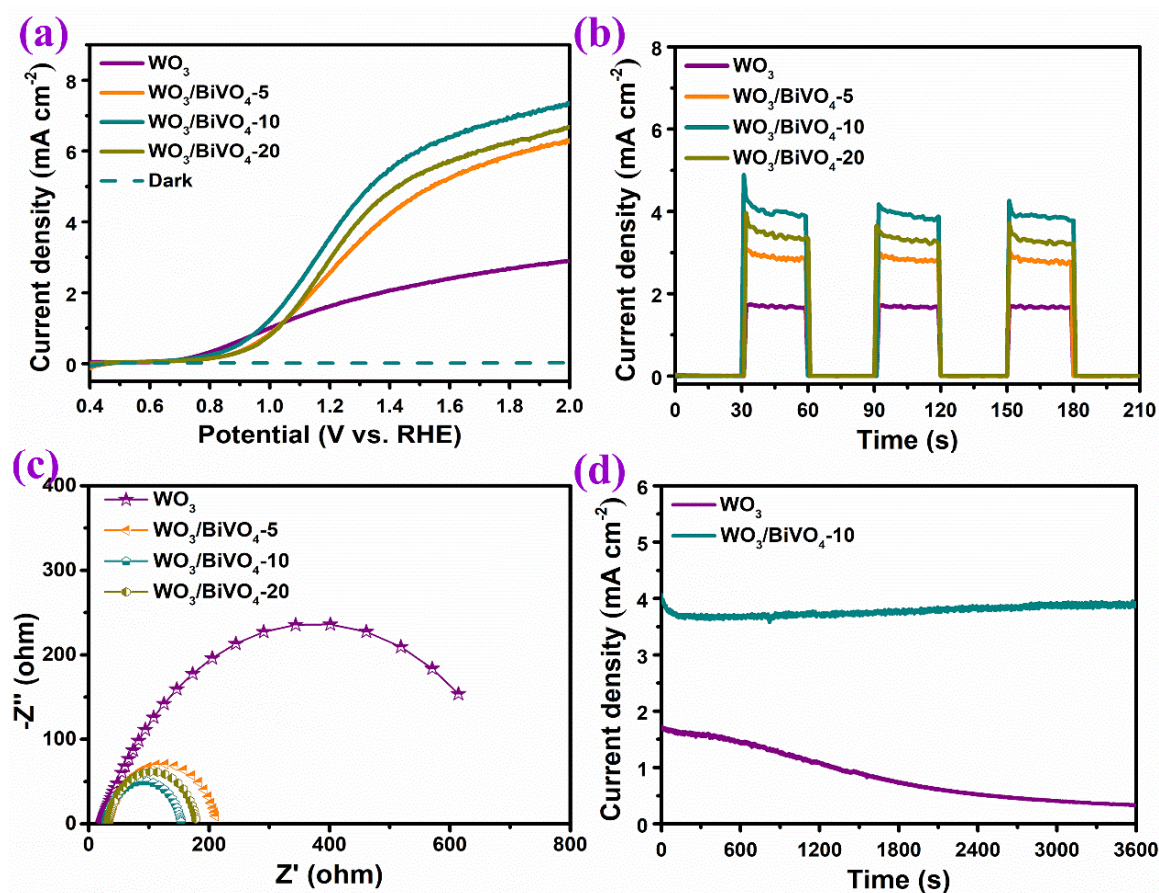


Figure 10. (a) Linear sweep voltammograms (LSV), (b) amperometric i - t curves under chopped light illumination, (c) electrochemical impedance spectra (EIS) and (d) the stability of WO_3 and $\text{WO}_3/\text{BiVO}_4$ arrays.

Table 1. Recent reports on the $\text{WO}_3/\text{BiVO}_4$ heterojunction photoanodes for solar water oxidation.

Structure of Photoelectrodes	Method	Electrolyte	Photocurrent Density at 1.23 V vs. RHE (mA cm^{-2})	Ref.
BiVO_4 layer/nanoplate-like WO_3	hydrothermal method + spin coating (20 cycles)	0.5 M Na_2SO_4	0.43	[34]
BiVO_4 layer/ WO_3 nanoplates	hydrothermal method + spin coating	0.5 M Na_2SO_4	0.62	[35]

Table 1. Cont.

Structure of Photoelectrodes	Method	Electrolyte	Photocurrent Density at 1.23 V vs. RHE (mA cm ⁻²)	Ref.
BiVO ₄ layers/a WO ₃ layer	spin-coating + repeated spin-coating	0.5 M Na ₂ SO ₄	1.25	[36]
BiVO ₄ layer/WO ₃ nanoplates	hydrothermal method + spin-coating deposition (4 cycles)	0.5 M Na ₂ SO ₄	1.93	[37]
WO ₃ nanoplates coated by BiVO ₄ nanoparticles	hydrothermal + spinning calcination	0.1 M KPi buffer solution	1.2	[38]
Island-like BiVO ₄ /Plate-like WO ₃	hydrothermal + spin coating	0.1 M Na ₂ SO ₄	4.2	[39]
BiVO ₄ nanodot/WO ₃ nanorods	glancing angle deposition + Pulsed electrodeposition	0.5 M KPi + 1 M Na ₂ SO ₃	4.55	[40]
BiVO ₄ nanoparticles/WO ₃ nanoplates	hydrothermal method + chemical bath deposition (20 times)	0.5 M Na ₂ SO ₄	1.7	[41]
coral-like BiVO ₄ /WO ₃	hydrothermal method + electrodeposition process	0.5 M phosphate buffer solution	2.9	[42]
BiVO ₄ nanoparticles/WO ₃ nanoplates	hydrothermal method + hydrothermal method	0.5 M (Na ₂ SO ₄ + Na ₂ SO ₃)	1.35	[43]
surface dispersed BiVO ₄ /WO ₃ nanoplates	hydrothermal method + solvothermal method	0.2 M KPi buffer solution	3.53	This work

The electrochemical impedance spectra of WO₃ and WO₃/BiVO₄ arrays are shown in Figure 10c to characterize the impedance at the semiconductor/electrolyte interface. The corresponding equivalent circuit is provided in Supplementary Figure S4. R_s stands for the series resistance. CPE is constant phase element and R_{ct} represents the charge transfer resistance of the electrode/electrolyte interface. The radius of the arc in the impedance spectrum indicates the charge transfer ability of the photoanodes, where the smaller the radius means the smaller the impedance and a better charge transfer ability. Compared with pure WO₃, the charge transfer impedance of WO₃/BiVO₄ decreases significantly, indicating that compositing BiVO₄ can effectively reduce the charge transfer impedance of the photoelectrode due to the formation of the heterojunction. Among the WO₃/BiVO₄ composite arrays, WO₃/BiVO₄-10 has the lowest charge transfer impedance, which is the most favorable for photogenerated carriers to transfer to the electrode surface to oxidize water. The arc radius of WO₃/BiVO₄-20 is larger than that of WO₃/BiVO₄-10, which further indicates that the larger charge transfer impedance of WO₃/BiVO₄-20 limits its PEC water oxidation performance. This is consistent with the morphology analysis results. Figure 10d is the photocurrent stability test of WO₃ and WO₃/BiVO₄-10 measured at 1.23 V (vs. RHE). Since WO₃ is easily oxidized, the stability is poor. After loading BiVO₄, the stability of WO₃/BiVO₄-10 was significantly improved; there was no significant drop during subsequent tests except for the initial current drop. The protective effect of the BiVO₄ layer for WO₃ can be verified. The formation of the WO₃/BiVO₄ heterojunction contributes to the enhanced separation of charge carriers and relieves the charge accumulation on the WO₃ surface.

The fabrication and the PEC water oxidation mechanism of the surface dispersed WO₃/BiVO₄ heterojunction is schematically illustrated in Figure 11. The BiVO₄-nanoparticle@WO₃-nanoflake structure, verified by the SEM and TEM measurements, can be prepared by carefully controlling the hydrothermal and solvothermal conditions. When used as photoanodes, both WO₃ and BiVO₄ can absorb light and generate an enhanced charge

carrier. Subsequently, the $\text{WO}_3/\text{BiVO}_4$ heterojunction promotes the directional migration of photogenerated carriers and, thus, improves charge separation across the WO_3 and BiVO_4 interface, where the WO_3 layer with better charge transfer ability has proper thickness to work as a skeleton to optimize the light absorption and provide the electron pathway to the FTO substrate at the same time. Meanwhile, the BiVO_4 nanoparticles with little size promote light absorption and facilitate charge carrier transfer. In addition, the surface dispersed structure of the BiVO_4 -nanoparticle@ WO_3 -nanoflake ensures that the photogenerated holes from both WO_3 and BiVO_4 can contribute to PEC water oxidation, which greatly helps to suppress the accumulation and recombination of charge carriers at the semiconductor interface, as confirmed by the increased photocurrent as well as stability.

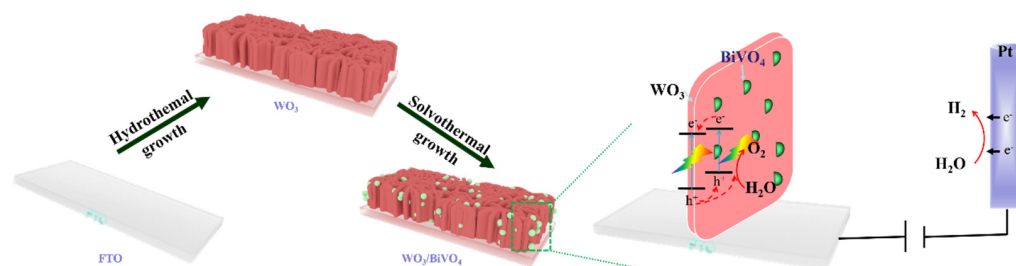


Figure 11. Schematic illustration of the formation and the PEC water oxidation mechanism of the $\text{WO}_3/\text{BiVO}_4$ arrays. The red flakes represent WO_3 and the green particles represent BiVO_4 .

3. Materials and Methods

3.1. Preparation of the WO_3 Nanoflake Arrays

All chemical reagents used in this work are analytical reagent. The tungsten trioxide nanoflake arrays were grown directly on the surface of F doped tin oxide (FTO) glass by the hydrothermal method, with sodium tungstate as tungsten source and oxalic acid as morphology control agent. Specifically, a certain amount of sodium tungstate and oxalic acid was weighed and dissolved completely in deionized water, where the molar ratio of Na_2WO_4 and $\text{H}_2\text{C}_2\text{O}_4$ was controlled at 1:2. Then, 0.5 mL of concentrated HCl was dropwise added into the above mixed solution. A piece of FTO conductive glass was placed in a reaction kettle and a certain amount of the above precursor solution was added. After the hydrothermal treatment at $150\text{ }^\circ\text{C}$ for 4 h, we can observe a yellow film on the surface of the FTO. Finally, the WO_3 nanoflake arrays were obtained by heat treatment at $500\text{ }^\circ\text{C}$ for 2 h in air. In order to optimize the synthesis conditions of the WO_3 film, precursors with different concentrations of sodium tungstate of 10, 15, 20, 50 and 80 mM were prepared and the corresponding WO_3 films were denoted as WO_3 -a, WO_3 -b, WO_3 -c, WO_3 -d and WO_3 -e.

3.2. Preparation of the $\text{WO}_3/\text{BiVO}_4$ Nanoflake Arrays

The $\text{WO}_3/\text{BiVO}_4$ composite films were further prepared by the solvothermal method. A certain amount of $\text{Bi}(\text{NO}_3)_3 \cdot 5\text{H}_2\text{O}$ was weighed and dissolved in ethylene glycol to obtain a colorless transparent solution. Afterwards, the equal molar mass NH_4VO_3 was added and stirred at an accelerated speed for another 20 min to form a uniform yellow suspension. The above-obtained WO_3 film on FTO was placed in a reaction kettle. After the solvothermal reaction at $160\text{ }^\circ\text{C}$ for 4 h, the film was fully rinsed with distilled water, dried in the oven at $60\text{ }^\circ\text{C}$ and changed into the $\text{WO}_3/\text{BiVO}_4$ composite film by heat treatment at $500\text{ }^\circ\text{C}$ in air. By controlling the concentration of $\text{Bi}(\text{NO}_3)_3 \cdot 5\text{H}_2\text{O}$ and NH_4VO_3 solution at 5, 10 and 20 mM, the $\text{WO}_3/\text{BiVO}_4$ films with different amounts of BiVO_4 were prepared, which were abbreviated as $\text{WO}_3/\text{BiVO}_4$ -5, $\text{WO}_3/\text{BiVO}_4$ -10 and $\text{WO}_3/\text{BiVO}_4$ -20, respectively.

3.3. Characterization

The X-ray diffraction (XRD) data of all samples were collected on Bruker's D8 advance diffractometer (Karlsruhe, Germany). The surface chemical composition of sample was

analyzed by the X-ray photoelectron spectra (XPS) on an ESCALab220i-XL electron spectrometer (Thermo Scientific, Waltham, MA, USA). The Hitachi S4800 (Tokyo, Japan) was used to obtain the scanning electron microscope (SEM) images. The transmission electron microscopy (TEM) images and the elemental mapping images were measured on Philips Tecnai G2 (Thermo Fisher, Waltham, MA, USA). UV-vis diffuse reflectance spectra were reflected by the UV-3600 spectrophotometer (Shimadzu, Tokyo, Japan).

3.4. Photoelectrochemical Tests

The photoelectrochemical tests of the photoanodes were measured by the three-electrode system on photoelectrochemical workstation (Zahner IM6, Zahner, Kronach, Germany), where the photoanode was used as the working electrode, Pt electrode as the counter electrode and saturated calomel electrode as the reference electrode. The simulated standard sunlight was the light source. The 0.2 mol L⁻¹ potassium phosphate buffer solution (pH = ~7) was used as electrolyte. PEC water oxidation was evaluated by the linear sweep voltammograms (LSV). The electrochemical impedance spectra (EIS) were measured from a frequency of 100,000 Hz to 0.1 Hz with a disturbing current voltage of 10 mV.

4. Conclusions

The WO₃/BiVO₄ composite photoanode with a structure of surface dispersed heterojunction was constructed, where a monoclinic WO₃ nanoflake array was grown on FTO substrate, with optimized morphology and thickness by controlling the appropriate concentration of precursor solution. The BiVO₄ nanoparticles were then uniformly loaded on the WO₃ nanoflakes using the solvothermal method. When used as photoanode, the WO₃/BiVO₄ composite exhibits superior PEC water oxidation performance with photocurrent of 3.53 mA cm⁻², which is twice that of pure WO₃ photoanode. This improved performance comes from the advantages of the unique surface dispersed WO₃/BiVO₄ array structure, as follows: (1) the proper thickness of the WO₃/BiVO₄ composites balanced the light absorption and the charge separation, contributing to more charge carriers reaching the interface; (2) the formation of the heterojunction immensely improves the separation efficiency of interfacial charge carriers; and (3) the surface dispersed heterojunction structure of BiVO₄-nanoparticle@WO₃-nanoflake provides a large heterojunction interface, which offers a large surface area and improves the stability of the photoelectrode.

Supplementary Materials: The following supporting information can be downloaded at: <https://www.mdpi.com/article/10.3390/molecules29020372/s1>, Figure S1: (a) UV-vis absorption spectra and (b) Tauc plots of WO₃ arrays; Figure S2: SEM images of WO₃/BiVO₄ composite arrays, (a) WO₃/BiVO₄-5, (b) WO₃/BiVO₄-10, (c) WO₃/BiVO₄-20; Figure S3: Cross-sectional view SEM image of WO₃/BiVO₄-10 and the corresponding elemental mapping; Figure S4: The equivalent circuit of the electrochemical impedance spectra.

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